IN THE UNITED STATES PATENT AND TRADEMARK OFFICE	
In re application of:	Date: November 26, 2007
Joel P. DeSouza et al.	
Serial Number: 10/604,146	Examiner: Jack S. J. Chen
Filed: June 27, 2003	Group Art Unit: 2813
	Conf. No. 1145
Title: SIMOX METHOD OF MAKING A	H. Daniel Schnurmann
BURIED OXIDE LAYER USING BASE	IBM Corporation
IMPLANT AND ROOM TEMPERATURE	Dept. 18G, B/321, Zip 482
IMPLANT	2070 Route 52
	Hopewell Junction, NY 12533

## **AMENDMENT SUBMITTED WITH RCE UNDER 37 CFR 1.114**

MS RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Communication dated July 26, 2007, Applicants submit the following amendments and remarks for the Examiner's consideration.